

# Charge collection in irradiated HV-CMOS detectors

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## Abstract

Active silicon detectors built on p-type substrate are a promising technological solution for large area silicon trackers such as those at the High Luminosity LHC, but the radiation hardness of this novel approach has to be evaluated. Active n-in-p strip detector prototypes CHESS2 for ATLAS with different substrate

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resistivities in the range of 20–1000  $\Omega$  cm were irradiated with neutrons and protons up to a fluence of  $2 \times 10^{15}$  n<sub>eq</sub> cm<sup>-2</sup> and  $3.6 \times 10^{15}$  n<sub>eq</sub> cm<sup>-2</sup>. Charge collection in passive test structures on the chip was evaluated using Edge-TCT and minimum ionising electrons from <sup>90</sup>Sr. Results were used to assess radiation hardness of the detector in the given fluence range and to determine parameters of initial acceptor removal in different substrates.

*Keywords:* Active silicon detectors; Charge collection efficiency; LHC upgrade

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## 1. Introduction

The High Luminosity LHC (HL-LHC) upgrade is foreseen to reach the instantaneous luminosity up to  $5 \times 10^{34}$  cm<sup>-2</sup> s<sup>-1</sup>, resulting in up to 200 proton-proton collisions within individual bunch crossings [1]. Since the existing Inner  
5 Detector of the ATLAS experiment [2] is not designed for the resulting readout rate and radiation damage it will have to be replaced in the Phase II Upgrade [3]. One technological option for the new detector is to use silicon sensors with CMOS readout electronics implemented on the same chip. To ensure sufficient radiation hardness and time resolution, charge collection has to rely on the drift  
10 of charge carriers in depletion zone. Therefore, the detector has to be designed to allow usage of sufficiently high bias voltages.

One of the CMOS technologies that allow high bias voltages is called HV-CMOS. The advantage of HV-CMOS detectors compared to traditional hybrid silicon modules is a possibility of a greater segmentation with a corresponding  
15 improvement in tracking resolution. In addition, the possibility to produce detectors in commercially available CMOS processes on industrial grade silicon wafers offered by a large number of vendors allows significantly simplified and faster production.

Depleted CMOS detectors are produced on p-type substrates, with a typical  
20 resistivity of 10 to a few 1000  $\Omega$  cm, and are usually operated under partial depletion. Numerous studies such as [4–11] have proved functionality of HV-CMOS detectors after irradiation to  $2 \times 10^{15}$  n<sub>eq</sub> cm<sup>-2</sup>, expected for the outer

layers of the ATLAS pixel detector at the HL-LHC. It was found that radiation induced removal of initial acceptors is an important effect in these substrates [12]. As a result a deeper depletion with more available charge can be achieved, leading to a better performance and a potentially longer detector lifetime.

HV-CMOS technology has been investigated as an option for the strip detector at the upgraded ATLAS experiment. A prototype chip named CHESS2 (CMOS HV/HR Evaluation for Strip Sensors) was produced for this purpose. This paper reports on effects of irradiation on charge collection in this detector.

## 2. Sample and irradiation

The CHESS2 chip [13] has been produced by AMS in a 350 nm HV-CMOS process. The chip size is 18.6 mm  $\times$  24.3 mm and consists of three strip arrays with digital signal encoding and several test structures for evaluating analogue and digital functionality of the chip, shown in Figure 1. Measurements presented in this work were made with two passive test structures (diodes), a  $3 \times 3$  n-in-p pixel array with a pixel size of 630  $\mu\text{m} \times 40 \mu\text{m}$  for edge transient current technique (Edge-TCT) and a large (pad-like) array of interconnected implants with a total size of 1260  $\mu\text{m} \times 1280 \mu\text{m}$  for measurements with  $^{90}\text{Sr}$ . The fill factor of collecting electrodes in the pixel is 53 % for both structures. CHESS2 chips are produced on four different p-type substrates with initial resistivities of 20, 50–100 (50), 200–300 (200), and 600–2000 (1000)  $\Omega \text{cm}$ . Values in parentheses are used in the rest of the text. Chips are thinned to 250  $\mu\text{m}$  without further back plane processing. High voltage of up to 120 V for reverse biasing of the sensor is applied between the collecting n-type electrodes and a p-type bias rail surrounding each pixel.

The samples were irradiated with reactor neutrons in Jožef Stefan Institute's TRIGA reactor [14], and with protons (Figure 1) at the CERN PS IRRAD facility (24 GeV/c, beam FWHM 14 mm) [15] and at Los Alamos Neutron Science Centre — LANSCE (800 MeV/c, beam FWHM 12 mm) up to maximal fluences of  $2 \times 10^{15} \text{ n}_{\text{eq}} \text{ cm}^{-2}$  and  $3.6 \times 10^{15} \text{ n}_{\text{eq}} \text{ cm}^{-2}$  for neutrons and protons respec-

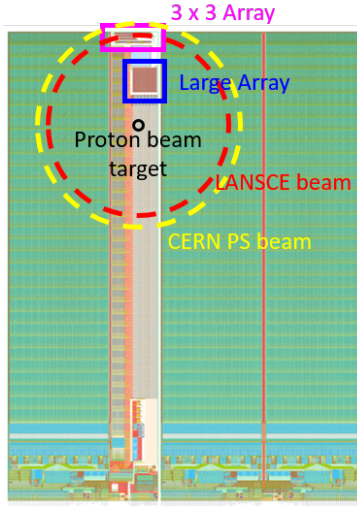


Figure 1: CHES2 sample with test structures. Position and size ( $1\sigma$ ) of the beams during proton irradiation are also shown.

tively. The irradiation summary is shown in Table 1. The proton irradiated chips were not irradiated uniformly so certain test structures may have received a lower local fluence than listed in Table 1. I-V measurements indicate that  
 55 some test structures irradiated at LANSCE have an order of magnitude smaller leakage current than PS irradiated samples, implying that the local fluence in these structures is lower than nominal.

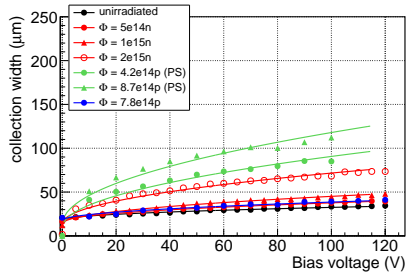
Measurements with all irradiated samples were carried out before and after annealing at  $60^\circ\text{C}$  for 80 minutes. Annealing had no measurable effect on  
 60 Edge-TCT measurements, whereas the amount of collected charge increased by  $\approx 10\%$  in annealed samples.

### 3. Edge-TCT measurements

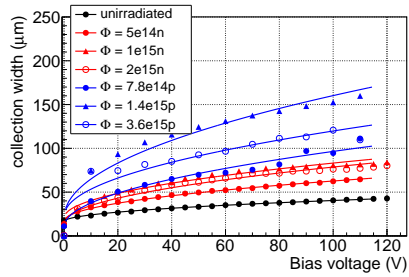
In Edge-TCT a narrow laser beam ( $\text{FWHM} = 10\ \mu\text{m}$ ) is directed to the edge of the detector mounted on high precision moving stages. More details about  
 65 this technique can be found in [16]. By measuring the response of the detector to a laser pulse at different depths the dimension of the depletion region can

	$\Phi_{\text{eq}}(20 \Omega \text{ cm})$	$\Phi_{\text{eq}}(50 \Omega \text{ cm})$	$\Phi_{\text{eq}}(200 \Omega \text{ cm})$	$\Phi_{\text{eq}}(1000 \Omega \text{ cm})$
PS (p)	4.2, 8.7	n/a	4.2, 8.7	4.2, 8.7
LANSCE (p)	7.8	7.8, 14, 36	7.8, 14, 36	7.8
Ljubljana (n)	1, 3, 5, 10, 20			

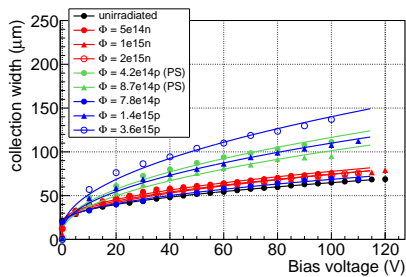
Table 1: Irradiated samples by fluence and initial resistivity. All fluences are given in  $10^{14} \text{ n}_{\text{eq}} \text{ cm}^{-2}$ .



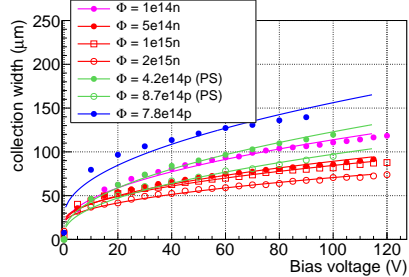
(a)  $20 \Omega \text{ cm}$



(b)  $50 \Omega \text{ cm}$



(c)  $200 \Omega \text{ cm}$



(d)  $1000 \Omega \text{ cm}$

Figure 2: Dependence of depletion depth on bias voltage for different fluences and initial wafer resistivities.

be estimated (see [16]). One dimensional Edge-TCT scans were made along the sample depth at the centre of the long side of the test structure. Depletion depth was evaluated as FWHM of resulting charge collection profiles. The dependence of depletion depth on bias voltage is shown in Figure 2 for different fluences and initial wafer resistivities. In  $20\ \Omega\text{ cm}$  samples, before irradiation a depletion depth of  $30\ \mu\text{m}$  can be achieved. After neutron irradiation the depletion depth gradually increases due to acceptor removal [12] and reaches  $70\ \mu\text{m}$  after a fluence of  $2 \times 10^{15}\ \text{n}_{\text{eq}}\ \text{cm}^{-2}$ . After proton irradiation (PS) a substantially larger depletion depth of  $80\ \mu\text{m}$  is observed already after  $4.2 \times 10^{14}\ \text{n}_{\text{eq}}\ \text{cm}^{-2}$  and a maximal depth of  $120\ \mu\text{m}$  is observed after  $8.7 \times 10^{14}\ \text{n}_{\text{eq}}\ \text{cm}^{-2}$ . However, the increase of the depletion depth in the sample irradiated at LANSCE to  $7.8 \times 10^{14}\ \text{n}_{\text{eq}}\ \text{cm}^{-2}$  is only marginal, but the received fluence is probably overestimated as discussed in Section 2. Increased depletion depth after irradiation was also measured on wafers with the initial resistivity of  $50$  and  $200\ \Omega\text{ cm}$ . Due to the higher substrate resistivity the depletion depth in these wafers is larger and in the  $200\ \Omega\text{ cm}$  wafer exceeds  $70\ \mu\text{m}$  at all fluences. In the  $1000\ \Omega\text{ cm}$  sample depletion depth could not be measured before irradiation because of an electrical breakdown. In irradiated chips of this resistivity the depletion depth decreases from  $120\ \mu\text{m}$  after  $1 \times 10^{14}\ \text{n}_{\text{eq}}\ \text{cm}^{-2}$  to  $70\ \mu\text{m}$  with increasing fluence, indicating that the effects of acceptor removal, if any, would be observed at lower fluences. For all initial resistivities the depletion depth is significantly larger after irradiation with protons than with neutrons at comparable fluences.

The data in Figure 2 were fitted with the function

$$W_{\text{depl}} = w_0 + \sqrt{\frac{2\varepsilon}{e_0 N_{\text{eff}}}} V_{\text{bias}}, \quad (1)$$

where  $\varepsilon$  is electrical permittivity of silicon,  $e_0$  the elementary charge, and  $N_{\text{eff}}$  the effective space charge concentration. The square root dependence comes from the abrupt junction, constant space charge approximation. An additional term  $w_0$  describes effects of built in voltage and finite beam width to account for the observed offset at zero volts. The dependence of fitted values of  $N_{\text{eff}}$  on fluence is shown in Figure 3. With neutron irradiated samples a characteristic

evolution of  $N_{\text{eff}}$  can be observed. The effective space charge concentration initially decreases due to acceptor removal. At higher fluences after the initial acceptors are removed the space charge concentration increases linearly due to radiation induced deep acceptors. The fluence at which the process of initial  
 100 acceptor removal is finished has been empirically found to depend on the initial resistivity of the material — removal in low resistivity material generally occurs at higher fluences. The behaviour of  $N_{\text{eff}}$  is described by the function [17]:

$$N_{\text{eff}} = N_{\text{eff0}} - N_c \cdot (1 - \exp(-c \cdot \Phi_{\text{eq}})) + g_C \cdot \Phi_{\text{eq}}, \quad (2)$$

where  $N_{\text{eff0}}$  is the initial doping concentration,  $N_c$  is the concentration of acceptors that are removed,  $c$  is the acceptor removal constant describing the  
 105 characteristic fluence for the removal, and  $g_C$  is stable damage introduction rate. The function was fitted to the neutron irradiation data and the fit results are shown in Table 2. For the 20, 50 and 200  $\Omega$  cm samples the factor  $g_C$  was fixed to the value of  $0.02 \text{ cm}^{-1}$  [18, 19]. The fitted acceptor removal constants  $c$  are shown in Figure 4 and are compared with other CMOS detectors [7–10]. Given that the acceptor removal is generally faster in less doped  
 110 material, the values of  $c$  for CHESS2 are lower than expected, especially for the 200  $\Omega$  cm material. However, the results are compatible with measurements on the H35Demo chips produced by the same manufacturer [9]. The measurements with the 1000  $\Omega$  cm sample were fitted with  $N_{\text{eff}} = N_{\text{eff0}} + g_C \cdot \Phi_{\text{eq}}$  with  $N_{\text{eff0}}$   
 115 and  $g_C$  as free parameters. The resulting value of  $g_C = (0.020 \pm 0.003) \text{ cm}^{-1}$  agrees with literature.

The values of  $N_{\text{eff}}$  measured with proton irradiated samples are lower than the values after neutron irradiation. The reason for this is a larger acceptor removal constant and smaller introduction rate of deep acceptors. The latter is  
 120 expected in oxygen rich silicon [18]. Given a large uncertainty on the fluence received by samples irradiated at LANSCE the value of  $g_C$  was estimated to be in the range of  $0.003\text{--}0.01 \text{ cm}^{-1}$ . For the same reason the acceptor removal parameters could not be estimated. A very low value of  $N_{\text{eff}}$  measured with the LANSCE irradiated 1000  $\Omega$  cm sample could be the consequence of acceptor

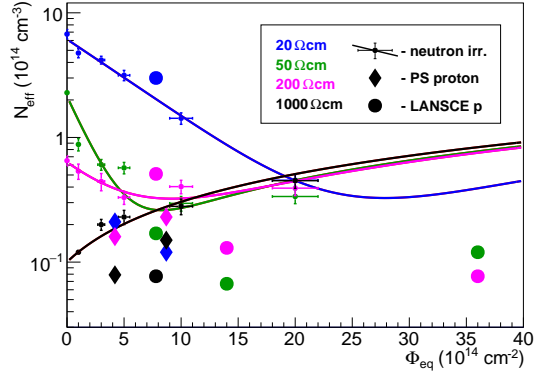


Figure 3: Dependence of effective space charge concentration  $N_{\text{eff}}$  on fluence for wafers of different initial resistivity. Data for neutron irradiated samples is fitted with the function 2 which describes acceptor removal.

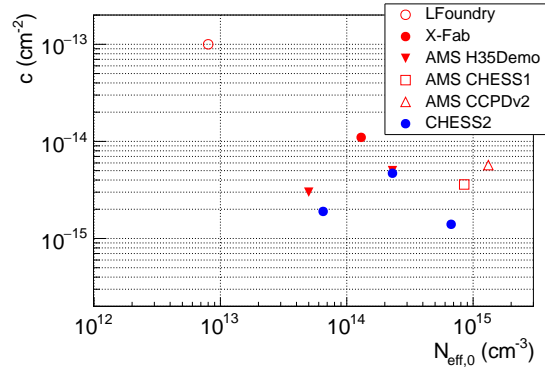


Figure 4: Comparison of measured acceptor removal constants with other HV-CMOS samples: LFoundry [7], X-Fab [8], AMS H35Demo [9], AMS CHES1 [10] and AMS CCPDv2 [10]. AMS H35Demo and CHES2 are produced by the same manufacturer in the same CMOS process and have matching values of  $c$ .



	20 $\Omega$ cm	50 $\Omega$ cm	200 $\Omega$ cm	1000 $\Omega$ cm
$N_{\text{eff0}} (10^{14} \text{ cm}^{-3})$	$6.1 \pm 0.4$	$2.1 \pm 0.1$	$0.63 \pm 0.06$	$0.010 \pm 0.003$
$N_c/N_{\text{eff0}}$	$1.06 \pm 0.02$	$0.98 \pm 0.02$	$0.95 \pm 0.28$	n/a
$c (10^{-14} \text{ cm}^2)$	$0.14 \pm 0.03$	$0.47 \pm 0.06$	$0.19 \pm 0.08$	n/a
$g_C (\text{cm}^{-1})$	0.02 (fixed)	0.02 (fixed)	0.02 (fixed)	$0.020 \pm 0.003$

Table 2: Fitted acceptor removal parameters for neutron irradiated samples.

125 removal effect, however the value before irradiation could not be measured to confirm this.

#### 4. Charge collection measurements

For measurements of charge collection the sample was mounted between two collimators with  $^{90}\text{Sr}$  source on one side and a scintillator coupled to a photomultiplier for triggering on the other side. The large pixel array was used for this measurement to ensure that all particles passing the collimators deposit their energy in the active region. Signal from a charge sensitive amplifier with a 25 ns shaping time was recorded by a digital oscilloscope. More details about the setup can be found in [20]. A convolution of Landau and Gauss function was fitted to the measured spectrum of collected charge. Because of a small signal to noise ratio the average value of the spectrum was used instead of the most probable value as the measure of collected charge. The ratio between the average and the most probable signal is approximately 1.25 for  $^{90}\text{Sr}$ [20].

Collected charge was measured for different bias voltages up to the electrical breakdown in the range of 80–120 V where noise increases significantly. Mean collected charge at 100 V is taken as a figure of merit. For samples where breakdown occurs below 100 V an extrapolation is made. The results are shown in Figure 5. There is a significant drop of collected charge after the first neutron irradiation step. This is explained by charge collection from the undepleted bulk by diffusion, whose contribution quickly diminishes by irradiation. For the 20, 50 and 200  $\Omega$  cm samples the collected charge increases again at higher fluences

due to acceptor removal. For 200 and 1000  $\Omega$  cm samples a collected charge above 2000 electrons is measured in the entire fluence range. The 200  $\Omega$  cm sample also shows a relatively small variation of charge with fluence, ranging  
150 between 2000 and 3000 electrons after neutron irradiation. As already indicated by Edge-TCT the collected charge in proton irradiated samples is higher due to a larger depletion region. In the 1000  $\Omega$  cm sample irradiated at LANSCE to  $7.8 \times 10^{14}$  n<sub>eq</sub> cm<sup>-2</sup> (probably overestimated) a charge of 16000 electrons is measured which is more than expected in an unirradiated sample using an  
155 extrapolation from Figure 3. This is an indication of acceptor removal also in the highest resistivity substrate.

Measurements with Edge-TCT have shown depletion depths in the range of 30–150  $\mu$ m, which would translate to 3000–15000 electrons of average deposited charge assuming an average charge deposition of 100 e–h pairs/ $\mu$ m [20]. How-  
160 ever, the measured charge is about a factor of two lower from this figure. A possible source of the mismatching is a low charge collection efficiency due to top biasing configuration described in Section 2. The shape of the electric field is such that charge carriers have to drift through a low electric field region at the end of the depletion zone in the substrate, where trapping probability is  
165 high after irradiation. As a result a substantial amount of charge carriers gets trapped and does not contribute the full signal, resulting in a reduced charge collection efficiency. This particularly impacts charge collection in pad geometry, where the weighting field is relatively uniform. In case of pixel or strip geometry where the largest weighting field is close to the implants this effect  
170 would not affect charge collection so much. A mitigation of this effect could be achieved by biasing the detector from the back, but this approach requires back plane processing [21].

## 5. Conclusions

Charge collection in neutron and proton irradiated CHES2 HV-CMOS  
175 chips was evaluated by Edge-TCT and minimum ionising electrons from <sup>90</sup>Sr.

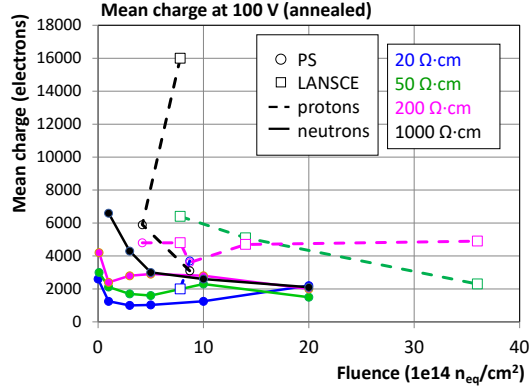


Figure 5: Collected charge in irradiated samples measured with  $^{90}\text{Sr}$ . Mean charge is shown due to a low signal to noise ratio of the measurement.

Samples of four different initial resistivities in the range of 20–1000  $\Omega$  cm were irradiated up to a fluence of  $2 \times 10^{15}$   $n_{\text{eq}} \text{ cm}^{-2}$  with neutrons and  $3.6 \times 10^{15}$   $n_{\text{eq}} \text{ cm}^{-2}$  with protons. With Edge-TCT depletion depths of  $> 70 \mu\text{m}$  at 100 V were measured in the 200 and 1000  $\Omega$  cm samples at all fluences. The measured depleted  
180 depth in 20–200  $\Omega$  cm samples increased after irradiation due to the the effective removal of initial acceptors. In 1000  $\Omega$  cm the acceptor removal was not directly observed and studies at lower fluences would be needed to measure this effect. It was found that acceptor removal constant is larger with protons, i.e. the removal is finished at a lower fluence than with neutrons, and that the stable  
185 damage introduction rate is lower. This results in larger depletion depths which mostly exceed 100  $\mu\text{m}$  in all samples.

The measurements of charge collection with  $^{90}\text{Sr}$  confirm that collected charge increases after irradiation in 20–200  $\Omega$  cm samples due to acceptor removal. The highest charge was measured with the 200 and 1000  $\Omega$  cm samples,  
190 where the average collected charge at 100 V exceeds 2000 electrons at all neutron fluences. In proton irradiated samples the collected charge is larger due to larger depletion depths.

The measured charge is less than the amount of charge deposited in depletion region estimated with Edge-TCT. A similar observation was made in [21], where

195 the effect was attributed to biasing the detector from the top, causing charge  
trapping in the low electric field region. This effect is smaller in segmented  
detectors or in detectors with a processed back plane.

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### References

- [1] G. Apollinari, et al., High-Luminosity Large Hadron Collider (HL-LHC):  
210 Preliminary Design Report, CERN Yellow Reports: Monographs, CERN, Geneva, 2015.
- [2] G. Aad, et al., ATLAS pixel detector electronics and sensors, JINST 3 (2008) P07007.
- [3] ATLAS Phase-II Upgrade Scoping Document, Technical Report CERN-LHCC-2015-020. LHCC-G-166, CERN, Geneva, 2015.  
215
- [4] D.-L. Pohl, et al., Radiation hard pixel sensors using high-resistive wafers in a 150 nm CMOS processing line, JINST 12 (2017) P06020.
- [5] H. Pernegger, et al., First tests of a novel radiation hard CMOS sensor process for Depleted Monolithic Active Pixel Sensors, JINST 12 (2017)  
220 P06008.

- [6] M. F. Garcia, C. Gallrapp, M. Moll, D. Muenstermann, Radiation hardness studies of neutron irradiated CMOS sensors fabricated in the AMS H18 high voltage process, JINST 11 (2016) P02016.
- [7] I. Mandić, et al., Neutron irradiation test of depleted CMOS pixel detector prototypes, JINST 12 (2017) P02021.
- [8] B. Hiti, et al., Charge collection properties in an irradiated pixel sensor built in a thick-film HV-SOI process, JINST 12 (2017) P10020.
- [9] E. Cavallaro, et al., Studies of irradiated AMS H35 CMOS detectors for the ATLAS tracker upgrade, JINST 12 (2017) C01074.
- [10] A. Affolder, et al., Charge collection studies in irradiated HV-CMOS particle detectors, JINST 11 (2016) P04007.
- [11] V. Fadeyev, et al., Investigation of HV/HR-CMOS technology for the ATLAS Phase-II Strip Tracker Upgrade, NIM A 831 (2016) 189 – 196. Proceedings of the 10th International Hiroshima Symposium on the Development and Application of Semiconductor Tracking Detectors.
- [12] R. Wunstorf, et al., Investigations of donor and acceptor removal and long term annealing in silicon with different boron/phosphorus ratios, NIM A 377 (1996) 228 – 233. Proceedings of the Seventh European Symposium on Semiconductor.
- [13] H. Grabas, Chess2 front end readout of the multi-segmented HV CMOS sensors, in: 10th International Meeting on Front-End Electronics, Warsaw, Poland, 2016.
- [14] L. Snoj, G. Žerovnik, A. Trkov, Computational analysis of irradiation facilities at the JSI TRIGA reactor, Applied Radiation and Isotopes 70 (2012) 483 – 488.
- [15] F. Ravotti, et al., IRRAD: The New 24GeV/c Proton Irradiation Facility at CERN (2015) 182–187. Proceedings of AccApp’15.

- [16] G. Kramberger, et al., Investigation of Irradiated Silicon Detectors by Edge-TCT, *IEEE Transactions on Nuclear Science* 57 (2010) 2294–2302.
- 250 [17] G. Kramberger, et al., Radiation effects in low gain avalanche detectors after hadron irradiations, *JINST* 10 (2015) P07006.
- [18] G. Lindström, et al., Radiation hard silicon detectors-developments by the RD48 (ROSE) collaboration, *NIM A* 466 (2001) 308 – 326. 4th Int. Symp. on Development and Application of Semiconductor Tracking Detectors.
- 255 [19] V. Cindro, et al., Radiation damage in p-type silicon irradiated with neutrons and protons, *NIM A* 599 (2009) 60 – 65.
- [20] G. Kramberger, et al., Charge collection properties of heavily irradiated epitaxial silicon detectors, *NIM A* 554 (2005) 212 – 219.
- 260 [21] I. Mandić, et al., Charge collection properties of irradiated depleted CMOS pixel test structures, *arXiv:1801.03671* (2018).